Notice of References Cited Application/Control No. 10/718,070 Examiner Patricia A. George Applicant(s)/Patent Under Reexamination HAMANN ET AL. Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-6,943,365	09-2005	Lowrey et al.	257/3
*	В	US-6,927,410	08-2005	Chen, Borny	257/2
* .	С	US-5,536,947	07-1996	Klersy et al.	257/3
*	D	US-2004/0178401	09-2004	Ovshinsky et al.	257/002
	Ε	US-			
	F	US-			
	G	US-			
	Н	US-			
	1	US-			
	J	US-			
	К	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р				 	
	Ø					
	R					
	S					
	Т					

NON-PATENT DOCUMENTS

*	tnclude as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)					
	U	Jpn. J. Appl. Phys. Vol.39 (2000) 745-751;Part 1, No. 2B, 28 February 2000 Investigation of Crystallization Behavior of Sputter-Deposited Nitrogen-Doped Amorphous Ge2Sb2Te5 Thin Films Hun Seo et al				
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	w					
	x					

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.